

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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Title of Invention

ALTERNATING PHASE-SHIFT MASK RULE COMPLIANT IC
DESIGN

Application Number : 10/708,684

Confirmation Number:

First Named Applicant: Franz Zach

Attorney Docket Number: FIS920040007

Art Unit: 2825

Examiner: Naum Levin

Search string: (6622288 or 6609245 or 6605481 or 6338922 or 6197456 or 6057063 or 20030093766 or 20030056190 or 20030014732 or 20030013024 or 20030008222 or 20020197546 or 20020012851).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
NL	1	6622288	2003-09-16	Wang et al.			
↑	2	6609245	2003-08-19	Liebmann et al.			
↑	3	6605481	2003-08-12	Wu et al.			
↑	4	6338922	2002-01-15	Liebmann et al.			
↓	5	6197456	2001-03-06	Aleshin et al.			
NL	6	6057063	2000-05-02	Liebmann et al.			

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
NL	1	20030093766	2003-05-15	Liebmann et al.			
↑	2	20030056190	2003-03-20	Liu et al.			
↑	3	20030014732	2003-01-16	Liu et al.			
↑	4	20030013024	2003-01-16	Pierrat			
↓	5	20030008222	2003-01-09	Pierrat			
↓	6	20020197546	2002-12-26	Pierrat			
NL	7	20020012851	2002-01-31	Coronel et al.			

Signature

Naum Levin

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